

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:	Sang-In LEE	Confirmation No.:	1997
Serial No.:	10/524,814	Art Unit:	2891
Filed:	May 5, 2006	Examiner:	Bradley SMITH
For:	<i>Atomic Layer Deposition of High-K Metal Oxides</i>	Attorney Docket No:	067538-5170-US

PETITION FOR EXTENSION OF TIME UNDER 37 CFR § 1.136(a)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

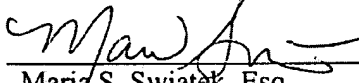
Sir:

It is respectfully requested that the time for response to the Non-Final Office Action dated May 28, 2008, be extended for a period of three-month from August 28, 2008 to November 28, 2008.

The fee for this extension is estimated to be \$1,110.00. Please charge the required fee to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310 (order no. 067538-5170-US).

Respectfully submitted,

Date: November 25, 2008



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